Docket No.: 2336-229

DEC 0 8 2004 (S)

IN THE CATED STATES PATENT AND TRADEMARK OFFICE

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Young Ho PARK et al.

Confirmation No. 2726

U.S. Patent Application No. 10/735,615

Group Art Unit: 2829

Filed: December 16, 2003

Examiner: Asok Sarkar

For:

METHOD FOR MANUFACTURING GALLIUM NITRIDE-BASED SEMICONDUCTOR LIGHT

EMITTING DEVICE

Dear Sir:

Transmitted herewith is an Amendment in the above identified application.

No additional fee is required.

Small entity status of this application has been established.

Also attached: Replacement Figures 1 and 2

The fee has been calculated as shown below:

	NO. OF CLAIMS	HIGHEST PREVIOUSLY PAID FOR	EXTRA CLAIMS	RATE	FEE
Total Claims	7	20	0	x \$ 18 =	\$0
Independent Claims	3	3	0	x \$ 88 =	\$0
		If multiple claims newly presented, add \$290.00 Fee for extension of time TOTAL FEE DUE			
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					\$0

П	A credit card authorization form in the amount of	is attached
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The Commissioner is hereby authorized to charge payment of any *deficiency* in fees associated with this communication or credit any overpayment, to Deposit Account No. <u>07-1337</u>, including any filing fees under 37 CFR 1.16 for presentation of extra claims and any patent application processing fees under 37 CFR 1.17.

Respectfully submitted,

LOWE MAUPTMAN GILMAN & BERNER, LLP

Benjamin J. Hauptman Registration No.: 29,310

USPTO Customer No. 22429 1700 Diagonal Road, Suite 300 Alexandria, Virginia 22314 (703) 684-1111 BJH/jk (703) 518-5499 Facsimile Date: December 8, 2004 Docket No.: 2336-229 PATENT

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In re Application of

Young Ho PARK et al. : Confirmation No. 2726

U.S. Patent Application No. 10/735,615 : Group Art Unit: 2829

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For: METHOD FOR MANUFACTURING GALLIUM NITRIDE-BASED

SEMICONDUCTOR LIGHT EMITTING DEVICE

AMENDMENT

COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria VA 22313-1450

Sir:

The following amendments and remarks are submitted in response to the Official Action dated September 10, 2004.